## IN THE CLAIMS

The following is the entire set of pending claims with mark-ups in accordance with revised 37 C.F.R. § 1.121.

Please amend Claim 21.

- 1. (canceled)
- 2. (canceled)
- 3. (canceled)
- 4. (canceled)
- 5. (canceled)
- 6. (canceled)
- 7. (canceled)
- 8. (canceled)
- 9. (canceled)
- 10. (canceled)
- 11. (canceled)
- 12. (canceled)
- 13. (canceled)
- 14. (canceled)
- 15. (canceled)
- 16. (previously presented) A quantum dot infrared photodetector structure comprising:
  - a gallium arsenide substrate;
- a first gallium arsenide layer as a first buffer layer formed on said gallium arsenide substrate;
- a first undoped Al<sub>x</sub>Ga<sub>1-x</sub>As layer as a blocking layer formed on said gallium arsenide layer;

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- a quantum dot structure layer comprising a plurality of stacked layers formed on said first undoped Al<sub>x</sub>Ga<sub>1-x</sub>As layer;
- a second undoped  $Al_xGa_{1-x}As$  layer as a second buffer layer formed on said quantum dot structure layer; and
- a second gallium arsenide layer as a contact layer formed on said second undoped Al<sub>x</sub>Ga<sub>1-x</sub>As layer.
- 17. (original) The structure according to claim 16, wherein said first gallium arsenide layer and said second gallium arsenide layer are n-type gallium arsenide layers.
- 18. (original) The structure according to claim 16, wherein said quantum dot structure layer is formed by multiple layers comprising indium arsenide quantum dots formed under an arsenic deficient condition and buried in an undoped gallium arsenide barrier layer.
- 19. (previously presented) The structure according to claim 16, wherein said quantum dot structure layer is made of one of silicon/silicon germanium composite and indium gallium arsenide/gallium arsenide composite.
- 20. (original) The structure according to claim 18, wherein the number of said multiple layers is ranged from 3 to 100.
- 21. (currently amended) The structure according to claim 16, wherein x values of aluminum contents of said first Al<sub>x</sub>Ga<sub>1-x</sub>As layer and said second Al<sub>x</sub>Ga<sub>1-x</sub>As layer are ranged from 10% to 100% 0.1 to 1 by atomic composition, respectively.
- 22. (original) The structure according to claim 16, wherein said first gallium arsenide layer has a thickness of about 1 μm.
- 23. (previously presented) A quantum dot infrared photodetector structure comprising:
  - a gallium arsenide substrate;
- a first gallium arsenide layer as a first buffer layer formed on said gallium arsenide substrate:

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- a first undoped aluminum gallium arsenide layer as a blocking layer formed on said gallium arsenide layer;
- a quantum dot structure layer comprising a plurality of stacked layers formed on said first undoped aluminum gallium arsenide layer;
- a second undoped aluminum gallium arsenide layer as a second buffer layer formed on said quantum dot structure layer; and
- a second gallium arsenide layer as a contact layer formed on said second undoped aluminum gallium arsenide layer.
- 24. (previously presented) The structure according to claim 23, wherein said first gallium arsenide layer and said second gallium arsenide layer are n-type gallium arsenide layers.
- 25. (previously presented) The structure according to claim 23, wherein said quantum dot structure layer is formed by multiple layers comprising indium arsenide quantum dots formed under an arsenic deficient condition and buried in an undoped gallium arsenide barrier layer.
- 26. (previously presented) The structure according to claim 23, wherein said quantum dot structure layer is made of one of silicon/silicon germanium composite and indium gallium arsenide/gallium arsenide composite.
- 27. (previously presented) The structure according to claim 25, wherein the number of said multiple layers is ranged from 3 to 100.
- 28. (previously presented) The structure according to claim 23, wherein said first gallium arsenide layer has a thickness of about 1 µm.

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